

Notice of References Cited	Application/Control No. 10/630,905	Applicant(s)/Patent Under Reexamination DONAHUE, JOHN J.	
	Examiner Rachna Singh	Art Unit 2176	Page 1 of 1

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NON-PATENT DOCUMENTS

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	U	Weske, Mathias, et al., "A Reference Model for Workflow Application Development Processes", ACM Database, 1999.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.